

IN THE SPECIFICATION:

Please amend paragraph [0062] as follows:

[0062] Photopolymers believed to be suitable for use with a stereolithography apparatus 1000 according to the present invention include, without limitation, ACCURA[®] SI 40 HC and AR materials and CIBATOOL SL 5170 and SL 5210 resins for the SLA[®] 250/50HR and SLA[®] 500 systems, ACCURA[®] SI 40 ND material and CIBATOOL SL 5530 resin for the SLA[®] 5000 and 7000 systems, and CIBATOOL SL 7510 resin for the SLA[®] 7000 system. The ACCURA[®] materials are available from 3D Systems, Inc., of Valencia, California, while the CIBATOOL resins are available from Ciba Specialty Chemicals ~~Company of Basel, Inc. of~~ Basel, Switzerland.